

X-Ray Photoelectron Spectroscopy (XPS)



Technical Parameters

Photoelectron Spectrometer:

PHI VersaProbe II

X-Ray Source: Aluminium anode (Al K α , photon energy 1486,6 eV)

Ion Source: Ar $^+$ Ions (Energy 0.25-5 keV)

Primary Beam: mono chromatised

AlK α - 1486,6 eV

Signal Detected: Photoelectrons

Elements Detected: Li – U Chemical bonding information

Lateral Resolution: 10 μm – 100 μm

Depth Resolution: 2 - 5 nm (Profiling Mode)

Detection Limit: 0.5 at%



Application areas

- Surface analysis of organic and inorganic materials
- Determining composition and chemical state information from surfaces
- Depth profiling for thin film composition
- Thin film oxide thickness measurements

Contact person

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